Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
Li	1	"20010055852"	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/11/09 10:42
L2	147	PZT with (tantalum or TaO2 or "TaO.sub.2") with (hafnium or "HfO.sub.2") with (zirconium or "ZrO.sub.2")	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/11/09 10:56
L3	1	1 and @ay<="2002"	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/11/09 10:44
L4	59	2 and @ay<="2002"	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/11/09 10:44
L5	40	PZT with ((hafnium adj silicate) or "HfSiO.sub.2")	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/11/09 10:58
L6	13	5 and @ay<="2002"	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/11/09 10:57
L7	80	PZT same ((hafnium adj silicate) or "HfSiO.sub.2")	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/11/09 10:58
L8	49	7 and @ay<="2002"	US-PGPUB; USPAT; EPO; JPO	OR .	ON	2005/11/09 10:58
L9	36	8 not 6	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/11/09 12:43
L10	54	Nallan-Padmapani-C.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/09 12:43
15151	22	Jin-guangxiang.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/09 12:43
L12	236	Kumar-Ajay.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/09 12:44
S10	1	vinh-Lan.xp. and (halfnium or "HfO.sub.2").clm.	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/11/08 18:24
S11	0	("vinh-Lan.xp.or" vinh-lan.xa.) and (halfnium or "HfO.sub.2").clm.	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/11/07 10:58

S12	0	("vinh-Lan.xp." or vinh-lan.xa.) and (halfnium or "HfO.sub.2").clm.	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/11/07 10:58
S13.	1	(vinh-Lan.xp. or vinh-lan.xa.) and (halfnium or:"HfO.sub.2").clm.	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/11/07 10:59
S14	4843	(hafnium or high\$1k or "HfO.sub. 2" or "ZrO.sub.2" or "ZrSiO.sub.2" or "HfSiO.sub.2" or "TaO.sub.2") same (CO or (carbon adj monoxide))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/07 11:21
S15	2250	(hafnium or high\$1k or "HfO.sub. 2" or "ZrO.sub.2" or "ZrSiO.sub.2" or "HfSiO.sub.2" or "TaO.sub.2") with (CO or (carbon adj monoxide))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/07 11:01
S16	65	(hafnium or high\$1k or "HfO.sub. 2" or "ZrO.sub.2" or "ZrSiO.sub.2" or "HfSiO.sub.2" or "TaO.sub.2") with (CO or (carbon adj monoxide)) with ("Cl.sub.2" or halogen)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/08 18:25
S17	41	S16 and @ay<="2002"	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/11/07 11:02
S18	800	(hafnium or high\$1k or "HfO.sub. 2" or "ZrO.sub.2" or "ZrSiO.sub.2" or "HfSiO.sub.2" or "TaO.sub.2") with (etch or etching)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/07 11:22
S19	24	S16 not S17	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/07 11:22
S20	4843	(hafnium or high\$1k or "HfO.sub. 2" or "ZrO.sub.2" or "ZrSiO.sub.2" or "HfSiO.sub.2" or "TaO.sub.2") same(CO or (carbon adj monoxide))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/07 16:16
S21	2882	S20 and (hydrogen or "H.sub.2" or chlorine or "Cl.sub.2")	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/07 16:16
S22	856	S21 and plasma	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/07 16:17
S23	56	S22 and (Applied adj Materials)"."	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/07 16:17

S24	56	S22 and (Applied adj Materials)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/07 16:17
S25	37980	(CO or (carbon adj monoxide)) with (chlorine or chloride or "Cl. sub.2")	US-PGPUB; USPAT; EPO; JPO	OR	ON	2005/11/08 18:25
S26	1571	S25 and (hafnium or high\$1k or "HfO.sub.2" or "ZrO.sub.2" or "ZrSiO.sub.2" or "HfSiO.sub.2" or "TaO.sub.2")	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/08 18:26
S27	203	S26 and (etch or etching)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/08 18:26
S28	158	S27 and @ay<="2002"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/11/08 18:26